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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/836,711	04/17/2001	Shinya Watanabe	114G1-144	7093
75	90 05/15/2003			
BRADLEY N. RUBEN, PC			EXAMINER	
463 FIRST ST., HOBOKEN, N.			EGAN, BRIAN P	
			ART UNIT	PAPER NUMBER
			1772	a
			DATE MAILED: 05/15/2003	7

Please find below and/or attached an Office communication concerning this application or proceeding.

			lk
	Application No.	Applicant(s)	
	09/836,711	WATANABE ET A	AL.
Office Action Summary	Examiner	Art Unit	
	Brian P. Egan	1772	
The MAILING DATE of this communication Period for Reply	n appears on the cover sh	neet with the correspondence ac	Idress
A SHORTENED STATUTORY PERIOD FOR R THE MAILING DATE OF THIS COMMUNICATI - Extensions of time may be available under the provisions of 37 C after SIX (6) MONTHS from the mailing date of this communicatio - If the period for reply specified above is less than thirty (30) days, - If NO period for reply is specified above, the maximum statutory of the status of the	ON. FR 1.136(a). In no event, however on. a reply within the statutory minimu period will apply and will expire SIX statute, cause the application to be	, may a reply be timely filed m of thirty (30) days will be considered time (6) MONTHS from the mailing date of this o come ABANDONED (35 U.S.C. § 133).	
1) Responsive to communication(s) filed on	24 February 2003.		
2a) This action is FINAL . 2b) ⊠	This action is non-final	l.	
Since this application is in condition for a closed in accordance with the practice up			ne merits is
Disposition of Claims			
4)⊠ Claim(s) <u>1-18</u> is/are pending in the applic	ation.		
4a) Of the above claim(s) is/are wit	hdrawn from consideration	on.	
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>1-18</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction a Application Papers	ind/or election requireme	ent.	
9)☐ The specification is objected to by the Exa	miner.		
10) ☐ The drawing(s) filed on is/are: a) ☐		to by the Examiner.	
Applicant may not request that any objection	to the drawing(s) be held in	n abeyance. See 37 CFR 1.85(a).	
11)☐ The proposed drawing correction filed on _	is: a)∏ approved l	b) disapproved by the Examir	ner.
If approved, corrected drawings are required	in reply to this Office action	1.	
12)☐ The oath or declaration is objected to by th	e Examiner.		
Priority under 35 U.S.C. §§ 119 and 120			
13)⊠ Acknowledgment is made of a claim for fo	reign priority under 35 U	.S.C. § 119(a)-(d) or (f).	
a) ☐ All b) ☐ Some * c) ☑ None of:			
 Certified copies of the priority docu 	ments have been receive	ed.	
2. Certified copies of the priority docur	ments have been receive	ed in Application No	
 3. Copies of the certified copies of the application from the Internation * See the attached detailed Office action for 	al Bureau (PCT Rule 17.	2(a)).	Stage
14) ☐ Acknowledgment is made of a claim for dor	•		ıl application).
a) 🗌 The translation of the foreign languag	e provisional application	has been received.	, ,
15) Acknowledgment is made of a claim for do Attachment(s)	mesuc priority under 35 t	J.S.C. 99 120 and/or 121.	
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-94 3) Information Disclosure Statement(s) (PTO-1449) Paper N	8) 5) 🔲 No	terview Summary (PTO-413) Paper No tice of Informal Patent Application (PT her:	
U.S. Patent and Trademark Office PTO-326 (Rev. 04-01) Off	ice Action Summary	Part of Paper No. 9	

Application/Control Number: 09/836,711

Art Unit: 1772

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-9, 11-14, and 16-18 are rejected under 35 U.S.C. 103(a) as being unpatentable over WO 00/19792 (hereinafter WO '792) in view of Yoshida et al. (#5,827,445).

WO '792 discloses a high current suppression shield having a sheet shape (Fig. 8) and comprising an adhesive layer (Fig. 8, #17) on at least one surface of a magnetic thin film. The magnetic thin film is provided on one surface of a film or sheet form substrate composed of a synthetic resin (Fig. 8, #15; see also Translation p. 2, paragraph [0016]). The adhesive layer is provided on one surface of the magnetic thin film with the substrate interposed therebetween (see Fig. 8). The magnetic thin film is provided on one surface of a film or sheet form substrate so that the magnetic thin film can be peeled away from the substrate (Fig. 8, #13).

WO '792 further teaches functionally equivalent magnetic compositions that may be used including iron, iron oxide, nickel, cobalt, ferrosilicon, permalloy, ferrite, sendust, amorphous alloy, and carbon (Translation p. 2, paragraph [0016]) but fails to teach the specific M-X-Y composition as claimed by the Applicant.

Yoshida et al., however, teach a composite magnetic article for electromagnetic interference suppression wherein the magnetic loss material is in granular form (Col. 4, lines 3-4) and is selected from the group consisting of Sendust, Permalloy, amorphous alloys, and other

Application/Control Number: 09/836,711

Art Unit: 1772

metallic soft magnetic materials (which would include any of the functionally equivalent materials taught by WO '792) (Col. 3, line 66 to Col. 4, line 2). The magnetic loss material is dispersed in a dielectric layer selected from the group consisting of AlO_x and SiO_x (Col. 4, lines 59-67). The magnetic loss material has a large magnetic loss and has a high imaginary part permeability over a wide high frequency range and variable or adjustable magnetic resonance frequencies within a broadened frequency range (Col. 1, lines 36-41; Col. 2, lines 42-47). Yoshida et al. further teach that varying annealing treatments are used to modify the magnetic resonance frequency (Col. 4, lines 38-41). The magnetic resonance frequency exceeds 10 MHz (see Table 1 (Col. 8)). The magnetic article is formed into any desired shape using known mixing and shaping apparatuses (Col. 5, lines 19-23) and the granular magnetic powder has an average thickness less than the thickness of the skin layer (see Abstract). The Examiner agrees with the Applicant's contentions that the magnetic properties of a material are affected by more than just the compositional chemistry of the magnetic material. Yoshida et al. teach more than just an equivalence in the compositional chemistry, however - Yoshida et al. teach an equivalent physical chemistry (i.e., a granular ferrous component dispersed in a matrix of AlO or SiO) and further teach that the size of the magnetic material is modified such that it is thinner than the skin layer as noted above – both characteristics detailed by the Applicant in their remarks as being applicable to a material's magnetic properties. Therefore, it would have been obvious to one of ordinary skill in the art at the time Applicant's invention was made to have modified the size of the granular magnetic material (using any known mixing and shaping apparatus as noted above), to have modified the granular material with any functionally equivalent magnetic material as detailed above, and/or to select an annealing treatment depending on the desired end magnetic

Application/Control Number: 09/836,711

Art Unit: 1772

resonance frequency such that the magnetic material falls within the Applicant's claimed ranges of the magnetic loss factor, saturation magnetization, magnetic material thickness, DC electric resistivity, mean particle diameter, and anistropic magnetic field, since it has been held both that discovering an optimum value of a result effective variable involves only routine skill in the art, *In re Boesch*, 617 F.2d 272, 205 USPQ 215 (CCPA 1980), and a change in size is generally recognized as being within the level of ordinary skill in the art. *In re Rose*, 105 USPQ 237 (CCPA 1955). Yoshida et al. teach the use of the aforementioned magnetic loss material for the purpose of providing a magnetic article with an improved complex permeability at a high frequency band adaptable for an electromagnetic interference suppressor. Thus, it would have been obvious through routine experimentation to one of ordinary skill in the art to have used a granular magnetic material in a magnetic thin film for the purpose of providing a magnetic article with an improved complex permeability at a high frequency band adaptable for an electromagnetic interference suppressor as taught by Yoshida et al.

Therefore, it would have been obvious to one of ordinary skill in the art at the time Applicant's invention was made to have modified WO '792 by using a granular magnetic material as taught by Yoshida et al. in order to provide a magnetic article with an improved complex permeability at a high frequency band adaptable for an electromagnetic interference suppressor.

3. Claim 15 is rejected under 35 U.S.C. 103(a) as being unpatentable over WO '792 in view of Yoshida et al. ('445), and further in view of *IEEE Transactions on Magnetics*.

WO '792 and Yoshida et al. teach a high-frequency current suppression body as detailed above. The aforementioned prior art fails, however, to teach a sputtered or vacuum deposited

Art Unit: 1772

thin film layer. *IEEE Transactions on Magnetics*, however, teach that it is notoriously well known in the art to form a magnetic material layer by sputtering (p.4499, Col. 2, Sec. III "Results and Dsicussion"). Sputtering is used for the purpose of providing stoichiometric compositions. Thus, it would have been obvious through routine experimentation to one of ordinary skill in the art at the time Applicant's invention was made to have modified the formation process of a magnetic thin film such that it is applied via a sputtering technique for the purpose of providing a stoichiometric composition as taught by *IEEE Transactions on Magnetics*.

Therefore, it would have been obvious to one of ordinary skill in the art at the time Applicant's invention was made to have modified that aforementioned prior art by applying the thin film via a sputtering technique as taught by *IEEE Transactions on Magnetics* in order to provide a stoichiometric composition.

Response to Remarks

- 4. Pursuant to the Applicant's remarks and amended claims, the Examiner has withdrawn the 35 U.S.C. 112, second paragraph rejections from the previous office action.
- 5. Applicant's arguments with respect to the 35 U.S.C. 102 and 103 rejections from the previous office action have been considered but are moot in view of the new ground(s) of rejection.

Page 6

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Brian P. Egan whose telephone number is 703-305-3144. The examiner can normally be reached on M-F, 8:30-5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Harold Y. Pyon can be reached on 703-308-4251. The fax phone numbers for the organization where this application or proceeding is assigned are 703-872-9310 for regular communications and 703-872-9311 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0661.

BPE /

May 14, 2003

HAROLD PYON

SUPERVISORY PATENT EXAMINER